UNIQUE SOURCE FOR SPACE MICROELECTRONICS

- -• 130 nm/250 nm SiGe BiCMOS
- -• 8" (200 mm) Wafer Processing Pilot Line
- -• Advanced Design Kits Digital and Mixed-Signal for ASIC and MMIC design
- -• Radiation Tolerant / Radiation Hard IPs
- Technology for Harsh Environments
- -O Multi Project Wafer Service IC Prototyping
- -O Low Volume Production
- Design Support

ABOUT IHP

IHP is a non-profit organization supported by the authorities of the state of Brandenburg and the German Federal government that performs R&D in the field of silicon-based systems, highest-frequency ICs and technologies for wireless and broadband communications especially suited for applications in the highest GHz band thanks to integrated HBT devices with high cut-off frequencies of up to 500 GHz Manufacturing and Value Added Services for commercial IC production are provided via IHP Solutions GmbH, a fully-owned subsidiary of IHP under private law.

OUR STRENGTHS

- -• IP design, back-end and integration
- -• Process or device characterization
- Silicon evaluation



We design your circuits based on available IPs in IHP's technologies!



IHP – Leibniz- Institute for High Performance Microelectronics

> Im Technologiepark 25 15236 Frankfurt (Oder)

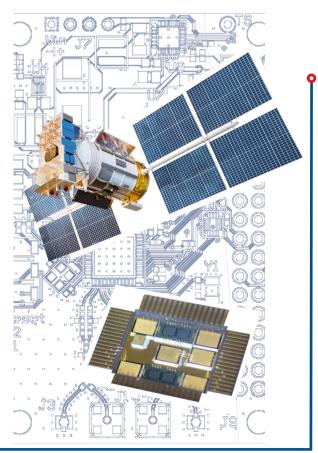
www.ihp-microelectronics.com, ihp@ihp-microelectronics.com

Contact: Dr. René Scholz scholz@ihp-microelectronics.com



03/2023

Radiation Hard Design Kit



Overview

IHP offers research partners and customers access to its powerful SiGe:C BiCMOS technologies and special integrated RF modules.

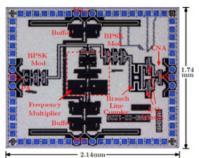
These technologies are especially suited for applications in the higher GHz bands (e.g. for wireless, broadband, radar).

LIBRARIES AND IPs

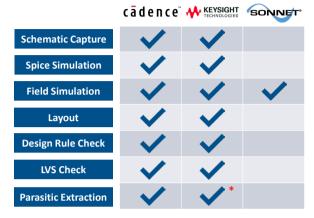
- Extended Operating Temperature Range : -55°
 C to +125° C
- -• MOS special layouts (ELT, SLT, JIC)
- MIM Capacitors, MOS Varactors, Inductor Models

Radiation Tolerant Libraries Radiation Levels :

- Bipolar (HBT) Devices TID > 800 krad
- -O CMOS TID levels 100 krad(Si) 300 krad(Si)
- -O CMOS SEU Threshold > 35MeV.cm²/mg -
- CMOS Special Cells SEU Threshold > 65 MeV. cm²/mg
- SEL Free > 65 MeV.cm²/mg



Supported EDA Tools for RH PDKs



SIGE BICMOS PROCESS CAPABILITY

SGB25RH	SG13RH
250nm SiGe BiCMOS	130nm SiGe BiCMOS
SiGe HBTs npn	SiGe HBTs npn
Peak f _T /f _{MAX} 75/95GHz	Peak f _T /f _{MAX} 220/340GHz
Mixed-Signal MMIC/ASIC	Mixed-Signal MMIC/ASIC
up to Ku-Band	up to Ka-Band
+2.5 V CMOS Core Voltage	+1.2 V CMOS Core Voltage
+2.5 V/+3.3 V Digital	+2.5 V/+3.3 V Digital
IO Pads	IO Pads

MODELING



Services

CMOS DIGITAL BACK-END

- -• Synthesis, Place & Route, Parasitic Extraction
- Research & Development of RHBD techniques
- -O Device Modeling
- -O TID Device Characterization
- -• SEU Testing with External Partners

EPPL REGISTERED



Listed on European Preferred Parts List

- SGB25RH validated & listed
- -O SG13RH is under evaluation process
- Extended life time endurance tested
- -O Component Standardisation Section at ESA
- European Space Components Coordination
- Supporting innovative technologies while maintaining quality assurance requirements

MODULES

Special Modules offered for R&D

- Radiation Hardened LDMOS
- Embedded RF-MEMS

